

## AMENDMENTS TO THE SPECIFICATION

Please insert the following paragraph on page 11 before line 20.

Figure 7 shows the silicon plate of Figures 1-5 after forming a surface layer according to an embodiment of a fabrication method of the invention,

Please replace the paragraph on page 15, beginning at line 15, with the following amended paragraph:

Thus, as illustrated in FIG. 7, a surface layer 6 (~~not shown~~), for example of  $\text{Si}_3\text{N}_4$ , may initially be deposited onto a first plate 1 with any roughness. A roughness  $r'.\text{sub.2}$  may then be created on the surface 2 of that surface layer 6, as explained above, for example by conforming a rough surface by deposition. However, instead of or in addition to this creation of roughness, the surface of the surface layer 6 may also be prepared to render it incompatible with unwanted sticking to the substrate intended to face the surface layer 6; using prior art methods, for example, the surface of a surface layer 6 of  $\text{Si}_3\text{N}_4$  may be rendered hydrophobic; materials other than silicon nitride  $\text{Si}_3\text{N}_4$  may be used here, such as diamond,  $\text{Al}_2\text{O}_3$  or  $\text{ZrO}_2$ .